

**Federal State Autonomous Educational Institution of Higher Education "Moscow
Institute of Physics and Technology
(National Research University)"**

APPROVED
**Head of Landau Phystech-School of
Physics & Research**
A.V. Rogachev

Work program of the course (training module)

course: Methods for the Synthesis of Nanomaterials/Методы синтеза наноматериалов
major: Photonics and Optical Informatics
specialization: Photonics, Quantum Technologies & 2D Materials/Фотоника, квантовые технологии и
двумерные материалы
Landau Phystech-School of Physics & Research
Chair of Physics and Technology of nanostructures
term: 2
qualification: Master

Semester, form of interim assessment: 3 (fall) - Exam

Academic hours: 30 AH in total, including:

lectures: 30 AH.

seminars: 0 AH.

laboratory practical: 0 AH.

Independent work: 30 AH.

Exam preparation: 30 AH.

In total: 90 AH, credits in total: 2

Author of the program: A.V. Arsenin, candidate of physics and mathematical sciences

The program was discussed at the Chair of Physics and Technology of nanostructures 20.05.2021

Annotation

The course includes a detailed consideration of methods of materials synthesis: deposition of thin films of metals, dielectrics, semiconductors (including analysis of thin film growth mechanisms, deposition methods and influence of various operating parameters on film characteristics), synthesis of two-dimensional and quasi-dimensional materials (CVD, etc.), exfoliation of two-dimensional materials, atomic layer deposition, pulsed laser deposition, chemical vapor deposition. Creation of van der Waals heterostructures. Optical and electron beam lithography. Local analysis, sputtering and etching of materials using focused ion beam.

1. Study objective

Purpose of the course

Introduction to basic methods of materials synthesis: deposition of thin films of metals, dielectrics, semiconductors (including analysis of thin film growth mechanisms, deposition methods and influence of various working parameters on film characteristics), synthesis of two-dimensional and quasi-dimensional materials (CVD, etc.), exfoliation of two-dimensional materials, atomic layer deposition, pulsed laser deposition, chemical vapor deposition, etc.

Tasks of the course

To study:

1. Method of deposition of thin films of metals, dielectrics, semiconductors.
2. Method of synthesis of two-dimensional and quasi-two-dimensional materials (CVD, etc.).
3. Method of exfoliation of two-dimensional materials.
4. Method of atomic layer deposition of thin films.
5. Method of pulsed laser deposition of thin films.
6. Methods of optical and electron-beam lithography.
7. Methods of local analysis, sputtering and etching of materials using a focused ion beam.

2. List of the planned results of the course (training module), correlated with the planned results of the mastering the educational program

Mastering the discipline is aimed at the formation of the following competencies:

Code and the name of the competence	Competency indicators
Gen.Pro.C-1 Gain fundamental scientific knowledge in the field of physical and mathematical sciences	Gen.Pro.C-1.1 Apply fundamental scientific knowledge in the field of physical and mathematical sciences
	Gen.Pro.C-1.2 Able to summarise and critically evaluate experiences and research results in the field of photonics and opto-informatics
	Gen.Pro.C-1.3 Understands the interdisciplinary links in mathematics and physics and is able to apply them to problems in photonics and opto-informatics
Gen.Pro.C-2 Acquire an understanding of current scientific and technological challenges in professional settings, and scientifically formulate professional objectives	Gen.Pro.C-2.3 Understand professional terminology used in modern scientific and technical literature and present scientific results in oral and written form within professional communication
Gen.Pro.C-3 Select and/or develop approaches to professional problem-solving with consideration to the limitations and specifics of different solution methods	Gen.Pro.C-3.1 Analyze problems, plan research strategy to achieve solution(s), propose, and combine solution approaches
	Gen.Pro.C-3.2 Employ research methods to solve new problems, and apply knowledge from various fields of science (technology)
	Gen.Pro.C-3.3 Gain knowledge of analytical and computational methods of problem-solving, understand the limitations for applying the obtained solutions in practice
Gen.Pro.C-4 Successfully perform a task, analyze the results and present conclusions, apply knowledge and skills in the field of	Gen.Pro.C-4.2 Apply knowledge in the field of physical and mathematical sciences to solve problems, make conclusions, and evaluate the obtained results

apply knowledge and skills in the field of physical and mathematical sciences and ICTs	Gen.Pro.C-4.3 Justify the chosen method of scientific research
Pro.C-1 Assign, formalize, and solve tasks, develop and research mathematical models of the studied phenomena and processes, systematically analyze scientific problems and obtain new scientific results	Pro.C-1.1 Locate, analyze, and summarize information on current research findings within a selected subject field
	Pro.C-1.2 Make hypotheses, build mathematical models of the studied phenomena and processes, evaluate the quality of the developed model
	Pro.C-1.3 Able to apply theoretical and/or experimental research methods in photonics and opto-informatics to a specific scientific problem and interpret the results obtained
Pro.C-2 Organize and conduct scientific research and testing independently or as a member (leader) of a small research team	Pro.C-2.1 Able to plan and carry out research in photonics and opto-informatics independently or as part of a research team
	Pro.C-2.2 Conduct tests of research results through scientific publications and participation in conferences

3. List of the planned results of the course (training module)

As a result of studying the course the student should:

know:

1. Basic methods of synthesis of nanomaterials.
2. Basic methods for creating nanostructures.
3. Basic methods of analysis of nanomaterials and nanostructures.

be able to:

1. Use methods of nanomaterials synthesis to create thin-film structures.
2. Use methods of nanostructuring to create nanodevices.

master:

A set of skills and knowledge necessary for the synthesis of nanomaterials and the creation of nanostructures.

4. Content of the course (training module), structured by topics (sections), indicating the number of allocated academic hours and types of training sessions

4.1. The sections of the course (training module) and the complexity of the types of training sessions

№	Topic (section) of the course	Types of training sessions, including independent work			
		Lectures	Seminars	Laboratory practical	Independent work
1	Nanoscale structures	4			4
2	Fabrication of thin film structures	3			3
3	Investigation of nanostructures by scanning probe microscopy methods	4			4
4	Investigation of nanostructures by transmission electron microscopy	4			4
5	Synthesis of two-dimensional materials	4			4
6	Exfoliation of two-dimensional materials	3			3
7	Manipulation of nano-objects and control of nano-movements	4			4
8	Processing of structures and fabrication of devices using nanotechnology	4			4
AH in total		30			30
Exam preparation		30 AH.			

Total complexity	90 AH., credits in total 2
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4.2. Content of the course (training module), structured by topics (sections)

Semester: 3 (Fall)

1. Nanoscale structures

Colloidal synthesis of nanoparticles. Laser ablation. Femtosecond laser ablation.

2. Fabrication of thin film structures

Thermal and electron-beam deposition in high vacuum. Pulsed laser sputtering. Ion-plasma methods of material deposition. Atomic layer deposition.

3. Investigation of nanostructures by scanning probe microscopy methods

Fundamentals of the method of scanning probe microscopy. Atomic force microscopy - working principles and measurement methods. Principles of operation of magnetic force microscopes.

4. Investigation of nanostructures by transmission electron microscopy

Transmission electron microscopy - principle of operation and measurement methods.

5. Synthesis of two-dimensional materials

CVD synthesis of graphene. CVD-synthesis of transition metal dichalcogenides. Growth of layered crystals.

6. Exfoliation of two-dimensional materials

Methods of preparation of crystal two-dimensional structures. Exfoliation of graphene, two-dimensional crystals of hexagonal boron nitride, exfoliation of transition metal dichalcogenides.

7. Manipulation of nano-objects and control of nano-movements

Laser transfer. Optical tweezers. Moving nanoobjects using an atomic force microscope.

8. Processing of structures and fabrication of devices using nanotechnology

Plasma chemical etching of substrate surfaces and nanoscale films. Optical lithography. Electronic lithography. Nanostructure fabrication using focused ion beam.

5. Description of the material and technical facilities that are necessary for the implementation of the educational process of the course (training module)

A set of electronic presentations/slides; an audience equipped with presentation equipment (projector, screen, computer / laptop); if necessary, special technical means for students with disabilities and persons with disabilities.

6. List of the main and additional literature, that is necessary for the course (training module) mastering

Main literature

Literature fund of the basic department:

1. Методы получения и исследования наноматериалов и наноструктур [Текст] : лабораторный практикум по нанотехнологиям : учебное пособие / ред. А. С. Сигов. - 2-е изд., перераб. и доп. - Москва : БИНОМ. Лаборатория знаний, 2013. - 184 с. : ил. - (Учебник для высшей школы).
2. Растровая электронная микроскопия для нанотехнологий. Методы и применение [Текст] / ред. пер. Т. П. Каминская ; пер.: С. А. Иванов, К. И. Домкин. - Москва : БИНОМ. Лаборатория знаний, 2013. - 582 с.
3. Наноструктуры и наноматериалы [Текст] : научное издание / Г. Цао, И. Ван ; пер.: А. И. Ефимова, С. И. Каргов ; науч. ред. русс. изд. В. Б. Зайцев ; Московский государственный университет им. М. В. Ломоносова., Научно-образовательный центр по нанотехнологиям. - 2-е изд., испр. - Москва : ФИЗМАТЛИТ, 2012. - 540 с.

Additional literature

1. Материалы и методы нанотехнологии [Текст] / В. В. Старостин - М.БИНОМ. Лаб. знаний, 2010

7. List of web resources that are necessary for the course (training module) mastering

Not used

8. List of information technologies used for implementation of the educational process, including a list of software and information reference systems (if necessary)

When preparing and conducting lectures, the Internet is used.

In addition, Libre Office is used, as well as the Ink Scape graphics package.

9. Guidelines for students to master the course

A student studying the discipline must, on the one hand, master the general conceptual apparatus, and on the other hand, must learn to apply theoretical knowledge in practice.

As a result of studying the discipline, the student must know the basic definitions and concepts, be able to apply the knowledge gained to solve various problems.

Successful completion of the course requires:

- attendance of all classes provided for by the curriculum for the discipline;
- keeping a synopsis of classes;
- student's intense independent work.

Independent work includes:

- reading recommended literature;
- study of educational material, preparation of answers to questions intended for independent study;
- solving problems offered to students in the classroom;
- preparation for the performance of tasks of the intermediate certification.

An indicator of mastery of the material is the ability to answer questions on the topics of the discipline without a synopsis.

It is important to achieve an understanding of the material being studied, not its mechanical memorization. If a student finds it difficult to study certain topics, questions, he/she should seek advice from a teacher.

Intermediate control of students' knowledge is possible in the form of solving problems in accordance with the topic of classes.

Assessment funds for course (training module)

major: Photonics and Optical Informatics
specialization: Photonics, Quantum Technologies & 2D Materials/Фотоника, квантовые технологии и двумерные материалы
Landau Phystech-School of Physics & Research
Chair of Physics and Technology of nanostructures
term: 2
qualification: Master

Semester, form of interim assessment: 3 (fall) - Exam

Author: A.V. Arsenin, candidate of physics and mathematical sciences

1. Competencies formed during the process of studying the course

Code and the name of the competence	Competency indicators
Gen.Pro.C-1 Gain fundamental scientific knowledge in the field of physical and mathematical sciences	Gen.Pro.C-1.1 Apply fundamental scientific knowledge in the field of physical and mathematical sciences
	Gen.Pro.C-1.2 Able to summarise and critically evaluate experiences and research results in the field of photonics and opto-informatics
	Gen.Pro.C-1.3 Understands the interdisciplinary links in mathematics and physics and is able to apply them to problems in photonics and opto-informatics
Gen.Pro.C-2 Acquire an understanding of current scientific and technological challenges in professional settings, and scientifically formulate professional objectives	Gen.Pro.C-2.3 Understand professional terminology used in modern scientific and technical literature and present scientific results in oral and written form within professional communication
Gen.Pro.C-3 Select and/or develop approaches to professional problem-solving with consideration to the limitations and specifics of different solution methods	Gen.Pro.C-3.1 Analyze problems, plan research strategy to achieve solution(s), propose, and combine solution approaches
	Gen.Pro.C-3.2 Employ research methods to solve new problems, and apply knowledge from various fields of science (technology)
	Gen.Pro.C-3.3 Gain knowledge of analytical and computational methods of problem-solving, understand the limitations for applying the obtained solutions in practice
Gen.Pro.C-4 Successfully perform a task, analyze the results and present conclusions, apply knowledge and skills in the field of physical and mathematical sciences and ICTs	Gen.Pro.C-4.2 Apply knowledge in the field of physical and mathematical sciences to solve problems, make conclusions, and evaluate the obtained results
	Gen.Pro.C-4.3 Justify the chosen method of scientific research
Pro.C-1 Assign, formalize, and solve tasks, develop and research mathematical models of the studied phenomena and processes, systematically analyze scientific problems and obtain new scientific results	Pro.C-1.1 Locate, analyze, and summarize information on current research findings within a selected subject field
	Pro.C-1.2 Make hypotheses, build mathematical models of the studied phenomena and processes, evaluate the quality of the developed model
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Pro.C-2 Organize and conduct scientific research and testing independently or as a member (leader) of a small research team	Pro.C-2.1 Able to plan and carry out research in photonics and opto-informatics independently or as part of a research team
	Pro.C-2.2 Conduct tests of research results through scientific publications and participation in conferences

2. Competency assessment indicators

As a result of studying the course the student should:

know:

1. Basic methods of synthesis of nanomaterials.
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3. Basic methods of analysis of nanomaterials and nanostructures.

be able to:

1. Use methods of nanomaterials synthesis to create thin-film structures.
2. Use methods of nanostructuring to create nanodevices.

master:

A set of skills and knowledge necessary for the synthesis of nanomaterials and the creation of nanostructures.

3. List of typical control tasks used to evaluate knowledge and skills

Not provided.

4. Evaluation criteria

List of control questions:

1. Physical principles of the electron-beam lithograph operation and methods of electron-beam lithography.
2. Physical principles underlying the atomic force microscope and basic methods of surface topography research.
3. Processing of measurement results obtained with an atomic force microscope.
4. Physical basis of optical lithography.
5. Chemical vapor deposition.
6. Physical principles of femtosecond laser ablation.
7. Thermal and electron-beam deposition in high vacuum.

Examples of examination papers:

Paper 1.

1. Physical principles of the electron-beam lithograph operation and methods of electron-beam lithography.
2. Colloidal synthesis of nanoparticles. Laser ablation. Femtosecond laser ablation.

Paper 2.

1. Physical principles underlying the atomic force microscope and basic methods of surface topography research.
2. Methods of preparation of crystal two-dimensional structures. Exfoliation of graphene, two-dimensional crystals of hexagonal boron nitride, exfoliation of transition metal dichalcogenides.

Assessment “excellent (10)” is given to a student who has displayed comprehensive, systematic and deep knowledge of the educational program material, has independently performed all the tasks stipulated by the program, has deeply studied the basic and additional literature recommended by the program, has been actively working in the classroom, and understands the basic scientific concepts on studied discipline, who showed creativity and scientific approach in understanding and presenting educational program material, whose answer is characterized by using rich and adequate terms, and by the consistent and logical presentation of the material;

Assessment “excellent (9)” is given to a student who has displayed comprehensive, systematic knowledge of the educational program material, has independently performed all the tasks provided by the program, has deeply mastered the basic literature and is familiar with the additional literature recommended by the program, has been actively working in the classroom, has shown the systematic nature of knowledge on discipline sufficient for further study, as well as the ability to amplify it on one’s own, whose answer is distinguished by the accuracy of the terms used, and the presentation of the material in it is consistent and logical;

Assessment “excellent (8)” is given to a student who has displayed complete knowledge of the educational program material, does not allow significant inaccuracies in his answer, has independently performed all the tasks stipulated by the program, studied the basic literature recommended by the program, worked actively in the classroom, showed systematic character of his knowledge of the discipline, which is sufficient for further study, as well as the ability to amplify it on his own;

Assessment “good (7)” is given to a student who has displayed a sufficiently complete knowledge of the educational program material, does not allow significant inaccuracies in the answer, has independently performed all the tasks provided by the program, studied the basic literature recommended by the program, worked actively in the classroom, showed systematic character of his knowledge of the discipline, which is sufficient for further study, as well as the ability to amplify it on his own;

Assessment “good (6)” is given to a student who has displayed a sufficiently complete knowledge of the educational program material, does not allow significant inaccuracies in his answer, has independently carried out the main tasks stipulated by the program, studied the basic literature recommended by the program, showed systematic character of his knowledge of the discipline, which is sufficient for further study;

Assessment “good (5)” is given to a student who has displayed knowledge of the basic educational program material in the amount necessary for further study and future work in the profession, who while not being sufficiently active in the classroom, has nevertheless independently carried out the main tasks stipulated by the program, mastered the basic literature recommended by the program, made some errors in their implementation and in his answer during the test, but has the necessary knowledge for correcting these errors by himself;

Assessment “satisfactory (4)” is given to a student who has discovered knowledge of the basic educational program material in the amount necessary for further study and future work in the profession, who while not being sufficiently active in the classroom, has nevertheless independently carried out the main tasks stipulated by the program, learned the main literature but allowed some errors in their implementation and in his answer during the test, but has the necessary knowledge for correcting these errors under the guidance of a teacher;

Assessment “satisfactory (3)” is given to a student who has displayed knowledge of the basic educational program material in the amount necessary for further study and future work in the profession, not showed activity in the classroom, independently fulfilled the main tasks envisaged by the program, but allowed errors in their implementation and in the answer during the test, but possessing necessary knowledge for elimination under the guidance of the teacher of the most essential errors;

Assessment “unsatisfactory (2)” is given to a student who showed gaps in knowledge or lack of knowledge on a significant part of the basic educational program material, who has not performed independently the main tasks demanded by the program, made fundamental errors in the fulfillment of the tasks stipulated by the program, who is not able to continue his studies or start professional activities without additional training in the discipline in question;

Assessment “unsatisfactory (1)” is given to a student when there is no answer (refusal to answer), or when the submitted answer does not correspond at all to the essence of the questions contained in the task.

5. Methodological materials defining the procedures for the assessment of knowledge, skills, abilities and/or experience

The course is graded at an exam. The questioning starts with a random task assigned to each student and time given for completion of the task. No aids are allowed. The student then proceeds to a chat with the examiner, at which he/she presents his/her solution to the assigned task. The examiner then asks the student several questions that evenly cover the course content. A final grade is assigned based on the quality of answers and demonstrated level of understanding.